Course code	Course Name	L-T-P- Credits	Ye Intro	ar of duction			
ME468	Nanotechnology	3-0-0-3	2	016			
Prerequisite : Nil							
Course Objectives:							
• To	introduce nanotechnology and nanostructures	AA	A				
• To	introduce fabrication and characterization techniques used i	n nanotec	hnology				
Syllabus: Introduction and scope, nanostructures Effect of Nanoscale dimensions on various properties, Fabrication methods, Characterisation methods, Applications of Nanotechnology (nano materials and devices), Nanomachines, Nanofluids, Nanoswitches, nano computers, nanofilters							
Expected	Outcomes:		_				
The stude	nts will be able to						
i. Ur	i. Understand properties of materials at nanoscale						
ii. Kr	now the fabrication and characterization methods used in nano	otechnolo	gy				
iii. A	cquaint with the various applications of nanotechnology						
 A.K. Bandyopdhyay, Nanomaterials, , New age international publishers,2008 Bharat Bhushan, Springer Handbook of Nanotechnology, 2010 Charles P Poole, Frank J Owens, Introduction to Nanotechnology, John Wiley and Sons, 2003 Jeremy Ramsden,Nanotechnology, William Andrew, Elsevier, 2011 T Pradeep, Nano: The essentials, McGraw – Hill education,2 007 V.S.Muralidharan, A Subramnya,Nano science and Technology, Ane books Pvt Ltd Reference books: Gregory Timp, Nanotechnology, Springer-Verlag, 2009 John Mongillo, Nano Technology, Greenwood Press, 2007 Kelsall Robert. W, Ian Hamley, MarkGeoghegan, Nanoscale Science and Technology, Wiley Eastern,2005 							
	COURSE PLAN						
Module	Contents 2014		Hours	End Sem. Exam. Marks			
Ι	Introduction and scope-Classification of nanostructures: Quantum dots, quantum wires, quantum wells, nanoclusters, nanotubes, super lattices, nanocrystalline materials-Effects of nanometer length scale – Changes to the system total energy, changes to the system structures.		7	15%			
п	Effect of Nanoscale dimensions on various properties – str thermal, chemical, mechanical, magnetic, optical and ele properties.	uctural, ectronic	7	15%			

III	Fabrication methods: Top down and bottom up approaches-Top down processes: Milling, Lithographics, machining process, pulsed laser methods- Bottom up processes: Vapour phase deposition methods, PVD, CVD, electro deposition, plasma assisted deposition process, MBE, chemical methods, colloidal and solgel methods	7	15%			
IV	Characterisation methods: General classification of characterization methods, Microscopy techniques: Scanning Electron Microscopy, Transmission Electron Microscopy, Scanning Tunneling Microscopy, Atomic Force Microscopy, Diffraction Techniques-Spectroscopy Techniques – Raman Spectroscopy, Surface analysis and depth profiling- Mechanical Properties- Magnetic and Thermal properties.	7	15%			
SECOND INTERNAL EXAMINATION						
V	Applications of Nanotechnology (nano materials and devices)- Applications of nanocomposites, nanocrystalline materials, nano layered structures, nanomagnetic materials-magneto resistance- Carbon nanotubes: SW, MW, nanostructured coatings- nano sensors: order from chaos, characterization, perception, nano sensor based on quantum size effect, Electrochemical sensors, Sensors based on physical properties, Nanobiosensors, smart dust	7	20%			
V1	Nanomachines: covalent and non covalent approaches, Molecular motors and machines, molecular devices, single molecular devices, practical problems with molecular device- Nanofluids: nanoparticles, preparation of nanofluids, thermophysical properties of nanofluids in comparison with base fluid. Nanoswitches - nano computers- nanofilters	7	20%			
		END SEMESTER EXAMINATION				

Question Paper Pattern

Maximum marks: 100

Time: 3 hrs

The question paper should consist of three parts

2014

Part A

There should be 2 questions each from module I and II Each question carries 10 marks Students will have to answer any three questions out of 4 (3X10 marks = 30 marks)

Part B

There should be 2 questions each from module III and IV Each question carries 10 marks Students will have to answer any three questions out of 4 (3X10 marks = 30 marks)

Part C

There should be 3 questions each from module V and VI Each question carries 10 marks Students will have to answer any four questions out of 6 (4X10 marks =40 marks) **Note:** Each question can have a maximum of four sub questions, if needed.